FOR PTO-1449 U.S. DEPARTMENT OF COMMERCE & (Modified) PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

| (Use Severa | I Sheets if | f Necessary |
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(37 CFR 1.96(b))

LC-425-US

APPLICATION NO.: 09/994,073

APPLICANT:

WEITONG SHI, et al.

FILING DATE:

GROUP:

November 27, 2001

ATTORNEY DOCKET NO.:

1711

Page 1 of 1

| U.S. PATENT DOCUMENTS | | | | | | |
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| EXAMINER'S INITIAL | PATENT NUMBER | ISSUE DATE | PATENTEE | CLASS | SUB CLASS | FILING DATE IF APPROPRIATE |
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| | NUMBER | DATE | PATENT OFFICE | CEAGG | CLASS | YES | NO |
| AB | 05214298 | 08/1993 | JP | C09J | 4/00 | Abstra | act |
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EXAMINER:

Initial citation considered. Draw line through citation if not in conformance and not considered.

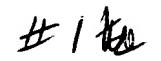
Include copy of this form with next communication to Applicant.

ATTORNEY DOCKET NO.: **APPLICATION NO.:** FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE LC-425 NYA (Modified) PATENT AND TRADEMARK OFFICE **INFORMATION DISCLOSURE APPLICANT:** STATEMENT BY APPLICANT WEITONG SHI, et al. **GROUP:** FILING DATE: (Use Several Sheets if Necessary) **NYA Concurrently Herewith** (37 CFR 1.98(b)) Page 1 of 1 **U.S. PATENT DOCUMENTS EXAMINER'S ISSUE** SUB **FILING DATE IF PATENT NUMBER CLASS PATENTEE** DATE **CLASS APPROPRIATE** INITIAL 02.17.70 260 836 3,496,250 Czerwinski 04.11.72 260 876R 3,655,825 Souder, et al. 06.06.72 260 857G 3,668,274 Owens, et al. Salensky 3,864,426 02.04.75 260 837R AB 11.15.77 Crivello 96 86P 4,058,400 Crivello 546 08.26.80 342 4,219,654 09.16.80 525 455 4,223,115 Zalucha, et al. Crivello 525 502 4,388,450 06.14.83 378 4,438,234 03.20.84 Rosenquist, et al. 524 O'Connor 525 295 04.03.84 4,440,910 525 126 4,452,944 06.05.84 Dawdy 525 111 4,769,419 09.06.88 Dawdy 522 31 5,070,117 12.03.91 Klemarczyk, et al. 556 5,079,378 01.07.92 Crivello 64 08.18.92 428 375 5,139,872 Lapin, et al. 31 05.24.94 Crivelllo, et al. 522 5,314,929 08.23.94 Mitry 525 10 5,340,873 522 31 01.23.96 Crivello 5,486,545 12.22.96 616 5,567,858 Crivello 568 525 77 5,641,834 06.24.97 Abbey, et al. 528 288 5,710,235 01.20.98 Abbey, et al. 6,225,408 05.01.01 Huang, et al. 525 88 TRANSLATION **DOCUMENT COUNTRY OR SUB PUBLICATION CLASS CLASS PATENT OFFICE** DATE NUMBER YES NO **PCT** W0 97/390074 23.10.97 C09J 4/00 OTHER DOCUMENTS (Including Author, Title, Date, Relevant Pages, Place of Publication)

| EXAMINER: | DATE CONSIDERED: |
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